

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant:	Haupt et al.	Docket No.:	QIM 2003 P 51718 US
Serial No.:	10/766,053	Art Unit:	2892
Filed:	January 28, 2004	Examiner:	Tran, Thanh Y.
For:	Method for N <sup>+</sup> doping of Amorphous Silicon and Polysilicon Electrodes in Deep Trenches		

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**RESPONSE UNDER 37 C.F.R. § 1.116**

Dear Sir:

Applicant respectfully submits the following remarks in response to the final Office Action dated October 27, 2009. Applicant respectfully requests that these remarks be entered pursuant to the provisions of 37 C.F.R. § 1.116, and respectfully requests reconsideration of the claims.